

Sheet 1 of 1Form PTO-1
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106452APPLICATION NO.
10/046,245

INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

APPLICANT(S)
Cathie J. BURKE et al.FILING DATE
January 16, 2002GROUP
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U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS
DLD	5,344,748	9/1994	Feely	430	330
DLD	5,738,799	4/1998	Hawkins et al.	216	27
DLD	5,485,181	1/1996	Convers	347	63
DLD	5,699,094	12/1997	Burke et al.	347	63

FOREIGN PATENT DOCUMENTS

DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

	S. Hagan et al., "Photosensitive Polyimide: Lithography in the Thick-Film Regime," Proceedings 11 th International Conference Photopolymers Principles, Processes, and Materials, Society of Plastics Engineers, Inc., Oct. 6-8, 1997, p. 422-437

EXAMINER

D. M. Hagan

DATE CONSIDERED

11/17/2003

Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Date: April 9, 2002